

	Application No.	Applicant(s)	
Notice of Allowability	09/808,790	VEPA ET AL.	
	Examiner	Art Unit	
	Lan Vinh	1765	
	Lan VIIII	1703	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate comm GHTS. This application is	in this application. If not included nunication will be mailed in due co	urse. THIS
1. This communication is responsive to Remark filed on 10/7/	′2003.		
2. A The allowed claim(s) is/are 1-18 and 26-28.			
3. \boxtimes The drawings filed on <u>15 March 2001</u> are accepted by the	Examiner.		
 4. ☐ Acknowledgment is made of a claim for foreign priority una) ☐ All b) ☐ Some* c) ☐ None of the: 	nder 35 U.S.C. § 119(a)-(d	or (f).	
 Certified copies of the priority documents have 	been received.		
Certified copies of the priority documents have	• •		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received: 5. Acknowledgment is made of a claim for domestic priority us reference was included in the first sentence of the specifical	ation or in an Application D	ata Sheet. 37 CFR 1.78.	specific
(a) The translation of the foreign language provisional a			
 Acknowledgment is made of a claim for domestic priority up in the first sentence of the specification or in an Application 	Data Sheet, 37 CFR 1.78		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of			
7. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached Exes reason(s) why the oath	(AMINER'S AMENDMENT or NO or declaration is deficient.	ΓICE OF
 8. ☐ CORRECTED DRAWINGS (as "replacement sheets") mus (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No 		∍w (PTO-948) attached	
(b) ☐ including changes required by the proposed drawing c	orrection filed whi	ch has been approved by the Eva	miner
(c) I including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No			
(b) In moraling changes required by the attached Externillor	57 anonamone 7 Gorminone	of the chief determined approximation	·
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on he margin according to 37 C	the drawings in the front (not the ba FR 1.121(d).	ack) of
9. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT FOR T	sit of BIOLOGICAL MA ^T HE DEPOSIT OF BIOLOG	FERIAL must be submitted. Not SICAL MATERIAL.	te the
Attachment(s)			
1☐ Notice of References Cited (PTO-892)	5∐ Notice of In	formal Patent Application (PTO-15	52)
 2 Notice of Draftperson's Patent Drawing Review (PTO-948) 3 Information Disclosure Statements (PTO-1449 or PTO/SB/08) Paper No 		ummary (PTO-413), Paper No	·
	^{1),} 7∏ Examiner's	Amendment/Comment	
4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8⊠ Examiner's 9⊟ Other	Statement of Reasons for Allowar .	псе
		Lan Vinh AU 163	
		Vilen	

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Allowable Subject Matter

1. Claims 1-18, 26-28 are allowed.

The following is an examiner's statement of reasons for allowance:

The reason for allowance of claims 1-17 has been stated in the previous office action (paper no.6). Regarding claim 18, the applicants have presented a persuasive argument that the cited prior art of record fails to disclose a method of processing a wafer prior to device formation thereon comprises, in order, the step of processing a peripheral edge of a wafer, the processing comprising defining an edge profile of the wafer and polishing the peripheral edge <u>after</u> the step of grinding the first and second surfaces of the wafer. In the contrary, the closest cited prior art of Vandamme et al (US 6,114,245) discloses a method of processing a wafer comprises the step of edge profiling of the wafer/processing the peripheral edge <u>in prior to</u> the step of grinding the first and second surfaces of the wafer (fig. 1)

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lan Vinh whose telephone number is 703 305-6302. The examiner can normally be reached on M-F 8:30-5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 703 305-2667. The fax phone number for the organization where this application or proceeding is assigned is 703 872-9310.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703 308-0661.

LV

December 10, 2003